



Application Note AN-V-200

Determination of thiourea in copper electrorefining solutions

Precision meets simplicity with the Multi-Mode Electrode pro

In the copper electrorefining process, chemical additives such as thiourea are utilized to enhance electrolytic refining and regulate the grain size of copper deposits. Precise quantification of thiourea is crucial for ensuring the quality of the refined copper. This requires its direct analysis in copper concentrates that contain sulfuric acid and trace amounts of chloride. However, the presence of chloride can interfere with the analysis.

This Application Note introduces a voltammetric method for the accurate quantification of

thiourea in copper electrolytes. The main advantage of this method lies in its ability to precisely determine thiourea levels even in the presence of high chloride concentrations within the sample matrix.

With precise control over thiourea levels, the copper refining process can be adjusted more precisely, leading to improvements in the consistency and quality of the refined copper. This method offers a simple and precise solution for maintaining optimal levels of thiourea.

SAMPLE

Cu electrorefining electrolyte

EXPERIMENTAL

Add the sample and the electrolyte solution into the measuring vessel and degas it for 5 min. The interfering effect of chloride is mitigated through the addition of masking analyte. The determination is carried out using parameters listed in **Table 1**. Quantification is done with the 884 Professional VA manual for MME (**Figure 1**) using two standard additions with thiourea standard addition solutions.



Figure 1. 884 Professional VA manual for MME

Table 1. Parameters

Parameter	Setting
Mode	DME
Start potential	0.3 V
End potential	0.2 V
Sweep rate	2 mV/s
Peak potential Thiourea	-1.45 V

ELECTRODES

- Multi-Mode Electrode pro

RESULTS

Figure 2 presents the result of the determination in an electrorefining solution containing 0.75 mg/L thiourea.

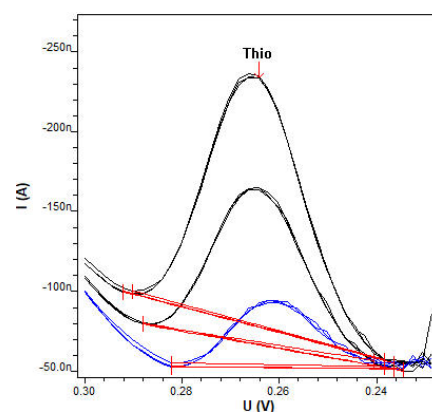


Figure 2. Determination of thiourea in an electrorefining electrolyte containing 0.75 mg/L thiourea

Table 2. Result

Sample	Thiourea in mg/L
Cu electrorefining electrolyte	0.71

Internal references: AW DE4-0164-102004

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CONFIGURATION



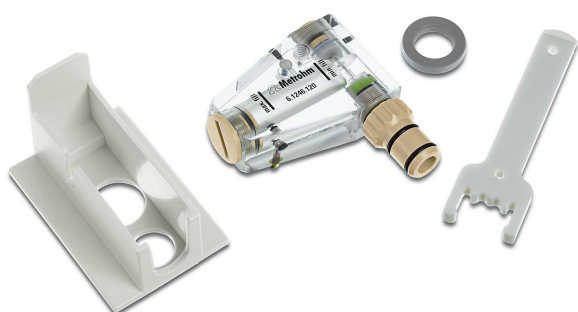
(MME) 884 Professional VA manual

用于多模式 (MME) 的 884 Professional VA manual 是借助多模式 pro 或 scTRACE Gold 或液滴使用伏安法和法行痕量分析的入器。此已的瑞士万通技与恒位/恒位以及外接的活 viva 件用,在重金属定域中展了新的前景。有的校准器的恒位在每次量之前均自冲洗行校准,保可能的高精度。

通此器也可使用旋行定,例如借助«循伏安溶出法»(CVS)、«循脉冲伏安溶出法»(CPVS)和位法(CP)定域中的有机添加。借助可更的量,可在使用不同的各用之快速切。

使用 **viva** 件行控制、数据采集和估。

用于 MME(多模式)的 884 Professional VA manual 供配大量附件,包括用于多模式 pro 的量。和 **viva** 可独。



Multi-Mode-Electrode pro

用于伏安法的汞。可作 DME、SMDE 或 HMDE 使用。
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